

FAST - (10786643.wsp.1)							File View Edit Tools Window Help		10/12/2004 11:31			
Save												
	Type	Hits	Search Text	DBs	Time Stamp							
1	BRS	4	(((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compress	USPAT; US-PGPUB	2004/10/12							
2	BRS	1	5567642.pn.	USPAT; US-PGPUB	2004/10/12							
3	BRS	3	("2000036605" "2000036567" "11340337" "2000183162").did.	JPO	2004/10/12							
4	BRS	1	"20010003364"	USPAT; US-PGPUB	2004/10/12							
5	BRS	2	(stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implant	USPAT; US-PGPUB	2004/10/12							
6	BRS	0	(stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implant	USPAT; US-PGPUB	2004/10/12							
7	BRS	1	(( (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or io	USPAT; US-PGPUB	2004/10/12							
8	BRS	3	(( (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or io	USPAT; US-PGPUB	2004/10/12							
9	BRS	0	(( (compressive or tensile or compressively) with (implant or implanted or implantation or implanting or ion\$1impl	USPAT; US-PGPUB	2004/10/12							
10	BRS	0	(( (compressive or tensile or compressively) with (implant or implanted or implantation or implanting or ion\$1impla	USPAT; US-PGPUB	2004/10/12							
11	BRS	2	(( (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or io	USPAT; US-PGPUB	2004/10/12							
12	BRS	0	(( (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or io	USPAT; US-PGPUB	2004/10/12							
13	BRS	0	(( (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or io	USPAT; US-PGPUB	2004/10/12							
14	BRS	2	(( (implant or implanted or implantation or implanting or ion\$1implant or ion\$1implanted or ion\$1implantation or io	USPAT; US-PGPUB	2004/10/12							
15	BRS	3	(( (compressive or tensile or compressively) with (implant or implanted or implantation or implanting or ion\$1imp	USPAT; US-PGPUB	2004/10/12							
16	BRS	0	(( (compressive or tensile or compressively) with ( ion\$1implant or ion\$1implanted or ion\$1implantation or ion\$1i	USPAT; US-PGPUB	2004/10/12							
17	BRS	3	(( (compressive or tensile or compressively) with (implant or implanted or implantation or implanting ) with (oxyg	USPAT; US-PGPUB	2004/10/12							
18	BRS	3	(( (compressive or tensile or compressively) with (implant or implanted or implantation or implanting ) with (oxyg	USPAT; US-PGPUB	2004/10/12							
19	BRS	3	438/766.ccls. and ( stress with (oxygen or carbon) )	USPAT; US-PGPUB	2004/10/12							
20	BRS	0	438/766.ccls. and ( (compressive or tensile or compressively) with (oxygen or carbon) )	USPAT; US-PGPUB	2004/10/12							
21	BRS	6	438/766.ccls. and ( (compressive or tensile or compressively) with stress )	USPAT; US-PGPUB	2004/10/12							
22	BRS	4	(( (stress) with (implant or implanted or implantation or implanting ) with (oxygen or carbon) with (relax or relaxe	USPAT; US-PGPUB	2004/10/12							
23	BRS	1	((lmc with (mosfet or fet or transistor or igfet))) and ((257/\$3.cor.) or (438/\$3.cor.))	USPAT; US-PGPUB	2004/10/12							
24	BRS	1	( stress with (silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with	USPAT; US-PGPUB	2004/10/12							
25	BRS	0	( stress with (capping or cap ) with (relax or relaxed or relaxing or ease or easing or eased) with (implant or im	USPAT; US-PGPUB	2004/10/12							
26	BRS	11	( stress with ((oxygen or carbon) adj. (implant or implanted or implantation or implanting or ion\$1implant or ion	USPAT; US-PGPUB	2004/10/12							
27	BRS	3	( stress with (nitride) with (relax or relaxed or relaxing or ease or easing or eased) with (implant or implanted o	USPAT; US-PGPUB	2004/10/12							
28	BRS	4	( stress with (nitride) with (compensate or compensated or compensating or compensation or balance or balan	USPAT; US-PGPUB	2004/10/12							
29	BRS	1	( stress with (silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with	USPAT; US-PGPUB	2004/10/12							
30	BRS	4	( stress with (oxygen or carbon or (o adj ion) or ( c adj ion) ) with (relax or relaxed or relaxing or ease or easing	USPAT; US-PGPUB	2004/10/12							
31	BRS	14	("5198371" and ((257/\$3.cor.) or (438/\$3.cor.))) and (( (oxygen or carbon or (o adj ion) or ( c adj ion) ) with (im	USPAT; US-PGPUB	2004/10/12							
32	BRS	1	("5198371" and ((257/\$3.cor.) or (438/\$3.cor.))) and (( (oxygen or carbon or (o adj ion) or ( c adj ion) ) with (im	USPAT; US-PGPUB	2004/10/12							
33	BRS	0	(( (oxygen or carbon or (o adj ion) or ( c adj ion) ) with heavy with stress)) and ((257/\$3.cor.) or (438/\$3.cor.))	USPAT; US-PGPUB	2004/10/12							
34	BRS	1	"20030162348"	USPAT; US-PGPUB	2004/10/12							
35	BRS	4	(((silicon\$1nitride or (silicon adj nitride) or sin or "si.sub.3 n.sub.4" or "si.sub.3n.sub.4" or si\$1n) with (compress	USPAT; US-PGPUB	2004/10/12							
36	BRS	1	"20030162348" and stress	USPAT; US-PGPUB	2004/10/12							
37	BRS	16	((carbon or oxygen) with stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1i	EPO; JPO; DERWENT	2004/10/12							
38	BRS	0	(( (oxygen or carbon or (o adj ion) or ( c adj ion) ) with heavy with stress)) and ((257/\$3.ccls.) or (438/\$3.ccls.)	USPAT; US-PGPUB	2004/10/12							
39	BRS	15	((((carbon or oxygen) with stress with (implant or implanted or implantation or implanting or ion\$1implant or ion\$1	USPAT; US-PGPUB	2004/10/12							
40	BRS	12	(( stress with (compensate or compensated or compensating or compensation or balance or balanced or balan	USPAT; US-PGPUB	2004/10/12							
41	BRS	1	6194256.pn.	USPAT; US-PGPUB	2004/10/12							

Type	Hits	Search Text	DBs	Time Stamp	Comments	Error Definit	Errors
BRS	1	"20030162348"	USPAT; US-PGPUB	2004/10/12 18:56			0